



## Open Challenges of On-Machine and In-Process Metrology for Precision Manufacturing

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Deadline for manuscript  
submissions:  
**closed (15 September 2023)**

### Message from the Guest Editors

Dear Colleagues,

This Special Issue will cover the current and most-pressing open challenges in the application of on-machine and in-process metrology for precision manufacturing.

Submissions are particularly welcomed in the following subject areas:

### 1. Measurement for applications in process monitoring and control

- Innovative measuring technologies for on-machine and in-process metrology of fundamental quantities;
- On-Machine and in-process measurement for monitoring components of manufacturing systems or entire manufacturing machines
- On-Machine and in-process measurement of roundness/cylindricity/straightness/flatness;
- On-Machine and in-process measurement of surface topography;

### 2. Measurement uncertainty estimation and calibration

- Estimation of measurement uncertainty and assessment of measurement error sources;
- Calibration and self-calibration of measuring systems for on-machine and in-process metrology.

### 3. Data processing

- Novel computational solutions for fast and lightweight





**metrol**  
metrology



measurement data processing

- AI and machine learning for on-machine and in-process metrology
- Digital twins to support on-machine and in-process metrology.

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## Editor-in-Chief

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## Message from the Editor-in-Chief

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